

L Number	Hits	Search Text	DB	Time stamp
-	3648	oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 13:05
-	46	oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) with vacuum	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:43
-	26	(oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) with vacuum) same (vessel or chamber)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:43
-	1	(oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) with vacuum) same (vessel or chamber) same reduct\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:22
-	8	(oxidiz\$4 with oxygen with reduct\$4 with (wafer or spec\$4 or substrate)) same (vessel or chamber)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:17
-	3	((oxidiz\$4 with oxygen with reduct\$4 with (wafer or spec\$4 or substrate)) same (vessel or chamber)) and (control\$4 near3 nozzle)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:12
-	0	(oxidiz\$4 with (wafer or spec\$4 or substrate)) and (oxygen with reduct\$4) and (control\$4 near3 nozzle) and ((multiple near3 nozzle) with reduct\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:20
-	0	(vacuum adj2 (chamber or vessel)) and (oxygen with reduct\$4) and (control\$4 near3 nozzle) and ((multiple near3 nozzle) with reduct\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:21
-	0	(vacuum adj2 (chamber or vessel)) and (oxygen with reduct\$4) and (control\$4 near3 nozzle) and ((multiple near3 nozzle) with (reduct\$4 or hydrogen))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:36
-	2	(oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) with vacuum) same reduct\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:24
-	36	((oxidiz\$4 with oxygen) with vacuum) same reduct\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:25
-	8	(oxygen with reduct\$4) and (control\$4 near3 nozzle) and ((multiple or number or two or three) with nozzle with (reduct\$4 or hydrogen))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:39

-	10	(oxygen with reduct\$4) and (control\$4 near3 (nozzle or outlet or jet)) and ((multiple or number or two or three) with nozzle with (reduct\$4 or hydrogen))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:40
-	17	(oxygen with reduct\$4) and (control\$4 near3 (nozzle or outlet or jet)) and ((multiple or number or two or three) with (nozzle or outlet or jet) with (reduct\$4 or hydrogen))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 17:05
-	104	oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) with reduct\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:44
-	39	(oxidiz\$4 with (oxygen or hydroxyl) with (wafer or spec\$4) with reduct\$4) and vacuum	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:50
-	835	(apparatus with oxidiz\$5) and (oxidation with reduction)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:55
-	105	(apparatus with oxidiz\$5) and (oxidation with reduction) and ((multiple or number or two or three) with (nozzle or outlet or jet))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/05 16:57
-	148	(oxygen with reduct\$4) and ((multiple or number or two or three) with (nozzle or outlet or jet) with (reduct\$4 or hydrogen))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/06 09:54
-	1101	438/770,771,773,694,735,738,769,787.ccls. and ((oxidation with reduction) or oxidizing)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/06 10:09
-	320	438/770,771,773,694,735,738,769,787.ccls. and ((oxidation with reduction) or oxidizing) and vacuum	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/06 10:10
-	254	438/770,771,773,694,735,738,769,787.ccls. and ((oxidation with reduction) or oxidizing) and vacuum and (chamber or vessel)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/06 10:11
-	116	438/770,771,773,694,735,738,769,787.ccls. and ((oxidation with reduction) or oxidizing) and vacuum and (chamber or vessel) and reduct\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/06 11:01
-	110	438/770,771,773,694,735,738,769,787.ccls. and ((oxidation near2 reductive) or oxidizing) and vacuum and (chamber or vessel) and reduct\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/06 11:02
-	110	438/770,771,773,694,735,738,769,787.ccls. and ((oxidation near2 reductive) or oxidizing) and vacuum and (chamber or vessel) and reduct\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/06 11:02

-	6061	438/770,771,773,694,735,738,769,787.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/06 11:02
-	9	(438/770,771,773,694,735,738,769,787.ccls. and ((oxidation near2 reductive) or oxidizing) and vacuum and (chamber or vessel) and reduct\$4) and ((port or discharge or nozzle or input or ingress or entrance or entry or (spray adj heads)) with (multiple or number or two or three))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/10/06 11:13